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APPLICATION NO.	F	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/000,323	-	12/04/2001	Masayuki Mishima	Q67519	9759	
	7590	12/17/2004		EXAMINER		
SUGHRUE			COLON, GERMAN			
2100 Pennsyl Washington,				ART UNIT PAPER NUMBER		
				2879		
				DATE MAILED: 12/17/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	<del></del>					
	10/000,323	MISHIMA, MASAYUK	a					
Office Action Summary	Examiner	Art Unit						
	German Colón	2879						
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the	correspondence addre	!SS					
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period v Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	. 36(a). In no event, however, may a reply be ti within the statutory minimum of thirty (30) da will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONI	mely filed ys will be considered timely. n the mailing date of this comm ED (35 U.S.C. § 133).	iunication.					
Status								
1)⊠ Responsive to communication(s) filed on 02 No.	ovember 2004.							
	action is non-final.							
3) Since this application is in condition for allowar	nce except for formal matters, pr	osecution as to the m	erits is					
closed in accordance with the practice under E	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims								
4)⊠ Claim(s) 1-11 and 21-23 is/are pending in the a	application.		·					
	4a) Of the above claim(s) is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.								
6)⊠ Claim(s) <u>1-11 and 21-23</u> is/are rejected.								
7) Claim(s) is/are objected to.	Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/or	Claim(s) are subject to restriction and/or election requirement.							
Application Papers								
9)☐ The specification is objected to by the Examine	r.							
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.								
Applicant may not request that any objection to the	drawing(s) be held in abeyance. Se	e 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correct	ion is required if the drawing(s) is of	jected to. See 37 CFR	1.121(d).					
11)☐ The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-	152.					
Priority under 35 U.S.C. § 119								
12)⊠ Acknowledgment is made of a claim for foreign a)⊠ All b)□ Some * c)□ None of:	priority under 35 U.S.C. § 119(a	u)-(d) or (f).						
1. Certified copies of the priority documents	s have been received.	•						
2. Certified copies of the priority documents	s have been received in Applicat	ion No						
3. Copies of the certified copies of the prior	•	ed in this National Sta	age					
application from the International Bureau	, , , , , , , , , , , , , , , , , , , ,							
* See the attached detailed Office action for a list	of the certified copies not receiv	ed.						
Attachment(s)								
1) Notice of References Cited (PTO-892)	4) Interview Summar	y (PTO-413)						
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail D	Date	:0) ·					
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	5)  Notice of Informal Other:	Patent Application (PTO-15	· ·					

### **DETAILED ACTION**

#### Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on November 02, 2004 has been entered.

# Response to Amendment .

- 2. The Amendment, filed on November 02, 2004, has been entered and acknowledged by the Examiner.
- 3. Cancellation of claims 12-20 has been entered.
- 4. Addition of claims 21-23 has been entered.

## Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. Claims 1-11 and 21-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Moriyama et al. (US 2002/0068192) in view of Onitsuka et al. (US 6,049,167), further in view of Tsai et al. (US 6,566,805).

Art Unit: 2879

Regarding claim 1, Moriyama discloses a method of producing a light-emitting device comprising the steps of disposing a transparent electrode 2, one or more organic layers 3 and a back side electrode 5 on a substrate 1 to provide a light-emitting structure, and disposing sealing parts 6 on said light-emitting structure to isolate said one or more organic layers from external air, wherein said one or more organic layers comprises a light-emitting layer 3 containing a phosphorescent compound (see paragraph [0048]). Moriyama teaches the detrimental effects caused by moisture and oxygen to the OLED (see paragraphs [0019] and [0020]) but is silent regarding their concentrations within the sealed atmosphere and the specific steps of the sealing process.

However, in the same field of endeavor, Onitsuka discloses a method of sealing a light emitting device comprising the steps of disposing a substrate containing a transparent electrode, a light emitting layer and a back side electrode, and sealing parts, in an inert gas atmosphere where the moisture concentration is 100 ppm or less (see at least Figs. 1 and 2 in view of Col. 3, lines 13-18) with the purpose of decreasing the costs of manufacture by reducing and simplifying the number of steps in the production of the organic EL devices, while eliminating the need of providing additional parts such as a filling port for introducing the inert gas to the sealed device (see Col. 2, lines 55-59 and Col. 3, lines 19-20). Further, Onitsuka teaches a moisture concentration below 100 ppm to decrease the degradation of the electrode layers and the light emitting layer, thereby reducing the number of dark spots in the device (see Col. 1, lines 27-32 in view of Col. 6, lines 1-3 and Col. 19, lines 27-29). Thus, it would have been obvious to one of ordinary skill in the art at the time the invention was made to seal the device of Moriyama by the method disclosed by Onitsuka and its specific moisture concentration, in order to decrease the

costs of manufacture by reducing and simplifying the number of steps in the production of the organic EL devices, while eliminating the need of providing additional parts such as a filling port for introducing the inert gas to the sealed device; and further, to decrease the degradation of the electrode layers and the light emitting layer, thereby reducing the number of dark spots in the device.

Moriyama-Onitsuka discloses the claimed invention but is silent regarding the preferred concentration of oxygen within the sealed atmosphere. However, in the same field of endeavor, Tsai teaches that in order to avoid the adverse effects of oxygen and moisture in an OLED, which deteriorate the performance and decrease the lifetime of the device (see Col. 2, lines 6-19, and Col. 3, lines 1-7), the required content of both oxygen and water (moisture) should be no more than 1 ppm (see Col. 3, lines 9-10). Thus, it would have been obvious to one of ordinary skill in the art at the time the invention was made to provide the inert gas of Moriyama-Onitsuka with an oxygen content of not more than 1 ppm, to avoid the adverse effects of oxygen which deteriorates the performance and decreases the lifetime of the device.

Regarding claim 2, Moriyama-Onitsuka discloses said one or more organic layers being isolated form external air after disposing said one or more organic layers until said sealing parts are disposed (see paragraph [0071] and [0082] of `192; and Col. 11, lines 1-39 of `167).

Regarding claims 3 and 4, Moriyama-Onitsuka-Tsai discloses both of said moisture concentration and said oxygen concentration being 1 ppm or less (see `167, Col. 6, lines 1-3; and `805, Col. 3, lines 9-10).

Referring to claim 5, Moriyama discloses at least one of said organic layers being formed by a wet film-forming method (see paragraph [0047], lines 9-10).

Application/Control Number: 10/000,323

Art Unit: 2879

Referring to claim 6, Moriyama discloses said one or more organic layers comprising a hole-injecting layer in contact with said light-emitting layer and said hole-injecting layer over said transparent electrode (see paragraph [0047], lines 3-9).

Referring to claim 7, Moriyama discloses at least both of said hole-injecting layer and said light-emitting layer being formed by a wet film-forming method (see paragraph [0047], lines 6-8 in view of lines 9-10).

Regarding claim 8, Moriyama discloses said one or more organic layers further comprising an electron-transporting layer between said light-emitting layer and said back side electrode (see paragraph [0047], lines 3-9).

Regarding claim 9, Moriyama discloses a weight ratio of said phosphorescent compound in said light-emitting layer being in a range of 0.1 to 70 wt% (see paragraph [0066] lines 4-5).

Regarding claim 10, Moriyama discloses said phosphorescent compound being an orthometallation complex (see paragraph [0048], lines 5-8, and paragraph [0066], line 4).

Regarding claim 11, Moriyama discloses an UV-hardening resin being used in combination with said sealing parts to isolate said one or more organic layers from external air (see paragraph [0056] lines 4-5).

Referring to claims 21-22, the claims are rejected over the reasons stated in the rejection of claims 1 and 2.

Referring to claim 23, the claim is rejected over the reasons stated in the rejection of claims 1, 2 and 5.

Page 6

7. Claims 1-11 and 21-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Baldo et al. (US 6,097,147) in view of Onitsuka et al. (US 6,049,167), further in view of Tsai et al. (US 6,566,805).

Regarding claim 1, Baldo discloses a method of producing a light-emitting device (see Fig. 3) comprising the steps of disposing a transparent electrode 511, one or more organic layers 512-515 and a back side electrode 516 on a substrate 510 to provide a light-emitting structure, wherein said one or more organic layers comprises a light-emitting layer 513 containing a phosphorescent compound. Baldo is silent regarding the limitation of "disposing sealing parts to isolate said one or more organic layers from external air, wherein said sealing parts are disposed in an inert gas atmosphere where both of a moisture concentration and oxygen concentration are 100 ppm or less".

However, in the same field of endeavor, Onitsuka discloses a method of sealing a light emitting device comprising the steps of disposing a substrate containing a transparent electrode, a light emitting layer and a back side electrode, and sealing parts, in an inert gas atmosphere where the moisture concentration is 100 ppm or less (see at least Figs. 1 and 2 in view of Col. 3, lines 13-18) with the purpose of decreasing the costs of manufacture by reducing and simplifying the number of steps in the production of the organic EL devices, while eliminating the need of providing additional parts such as a filling port for introducing the inert gas to the sealed device (see Col. 2, lines 55-59 and Col. 3, lines 19-20). Further, Onitsuka teaches a moisture concentration below 100 ppm to decrease the degradation of the electrode layers and the light emitting layer, thereby reducing the number of dark spots in the device (see Col. 1, lines 27-32 in view of Col. 6, lines 1-3 and Col. 19, lines 27-29). Thus, it would have been obvious to one of

Art Unit: 2879

ordinary skill in the art at the time the invention was made to seal the device of Baldo by the method disclosed by Onitsuka and its specific moisture concentration, in order to decrease the costs of manufacture by reducing and simplifying the number of steps in the production of the organic EL devices, while eliminating the need of providing additional parts such as a filling port for introducing the inert gas to the sealed device; and further, to decrease the degradation of the electrode layers and the light emitting layer, thereby reducing the number of dark spots in the device.

Baldo-Onitsuka discloses the claimed invention but is silent regarding the preferred concentration of oxygen within the sealed atmosphere. However, in the same field of endeavor, Tsai teaches that in order to avoid the adverse effects of oxygen and moisture in an OLED, which deteriorate the performance and decrease the lifetime of the device (see Col. 2, lines 6-19, and Col. 3, lines 1-7), the required content of both oxygen and water (moisture) should be no more than 1 ppm (see Col. 3, lines 9-10). Thus, it would have been obvious to one of ordinary skill in the art at the time the invention was made to provide the inert gas of Baldo-Onitsuka with an oxygen content of not more than 1 ppm, to avoid the adverse effects of oxygen which deteriorates the performance and decreases the lifetime of the device.

Regarding claim 2, Baldo-Onitsuka-Tsai discloses said one or more organic layers being isolated form external air after disposing said one or more organic layers until said sealing parts are disposed (see Col. 11, lines 1-39 of `167).

Regarding claims 3 and 4, Baldo-Onitsuka-Tsai discloses both the moisture concentration and the oxygen concentration being 1 ppm or less.

Art Unit: 2879

Regarding claim 5, Baldo discloses the at least one of said organic layers being formed by a wet film-forming method (see Col. 5, lines 49-51).

Regarding claim 6, Baldo discloses said one or more organic layers comprising a hole-injecting layer in contact with said light-emitting layer and said hole-injecting layer over said transparent electrode (see Fig. 3).

Referring to claim 7, Baldo discloses at least both of said hole-injecting layer and said light-emitting layer being formed by a wet film-forming method (see Col. 5, lines 49-51).

Referring to claim 8, Baldo discloses said one or more organic layers further comprising an electron-transporting layer between said light-emitting layer and said back side electrode (see Fig. 3).

Referring to claim 9, Baldo discloses a weight ratio of said phosphorescent compound in said light-emitting layer being in a range of 0.1 to 70 wt% (see Col. 6, line 11).

Referring to claim 10, Baldo discloses said phosphorescent compound being an orthometallation complex (see Col. 6, line 11).

Regarding claim 11, Baldo-Onitsuka-Tsai discloses an UV-hardening resin being used in combination with said sealing parts to isolate said one or more organic layers from external air (see '167, at least Col. 3, lines 20-21).

Referring to claims 21-22, the claims are rejected over the reasons stated in the rejection of claims 1 and 2.

Referring to claim 23, the claim is rejected over the reasons stated in the rejection of claims 1, 2 and 5.

Application/Control Number: 10/000,323 Page 9

Art Unit: 2879

## Response to Arguments

8. Applicant's arguments with respect to the claims have been considered but are moot in view of the new ground(s) of rejection.

The Examiner has presented new grounds of rejection to clarify the position taken in the Advisory Action mailed August 31, 2004. The new rejection clearly teaches the desirability of including an inert gas with low oxygen and moisture concentrations in the process of sealing the device, without requiring more than ordinary skills in the art, as alleged by Applicant.

# **Contact Information**

Any inquiry concerning this communication or earlier communications from the examiner should be directed to German Colón whose telephone number is 571-272-2451. The examiner can normally be reached on Monday thru Thursday, from 8:30 to 6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimesh Patel can be reached on 571-272-2457. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Xc

Karabi Guharay